

IN THE SPECIFICATION

Please substitute the following paragraph 33 for the originally filed paragraph. A copy of this paragraph showing the amendment is attached as Appendix B.

[33] Next, a mask 24 is provided over the silicon layer 15. Although the mask 24 is illustrated as located on Si layer 15, the mask 24 could also be located over the silicon layer 15, e.g., with intervening layers, films, or other structures. The type and size of mask 24 on the silicon layer 15 can vary depending on the required processing requirements. In one aspect of the present invention, the mask described below is used.